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Serial No.: 10/707,388

Conf. No.: 1387

OCT 14 2005

Filing Date: 12/10/2003

Art Unit: 2891

Applicant: Divakaruni et al.

Examiner: Fulk, Steven J.

Title: SILICIDE RESISTOR IN BEOL
LAYER OF SEMICONDUCTOR
DEVICE AND METHODDocket No.: FIS920030274US1
(IBMF-0032)**COMMISSIONER FOR PATENTS****DESTINATION FACSIMILE NUMBER: 571-273-8300**

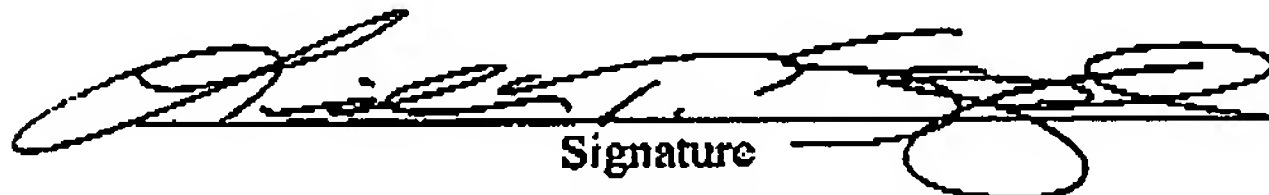
Transmitted herewith is:

Request for Reconsideration in 8 pages

in the above identified application.

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In Re Application of: Divakaruni et al.

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DEVICE AND METHOD

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Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REQUEST FOR RECONSIDERATION

Sir:

I. INTRODUCTORY COMMENTS:

In response to the Office Action of July 28, 2005, please reconsider the above-referenced patent application in view of the following remarks: